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IN THIS ISSUE

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Cover

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Inside cover

See Svenja Morsbach et al., pp. 1377-1385. Image reproduced by permission of Stefan Schuhmacher from Nanoscale Horiz.. 2023, 8, 1377.

EDITORIAL

1300

Nanoscale Horizons Emerging Investigator Series: Dr Ran Long, University of Science and Technology of China, China

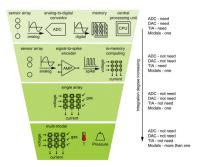


REVIEWS

1301

Four levels of in-sensor computing in bionic olfaction: from discrete components to multi-modal integrations

Lin Liu, Yuchun Zhang and Yong Yan*



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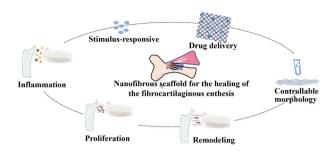


REVIEWS

1313

Nanofibrous scaffolds for the healing of the fibrocartilaginous enthesis: advances and prospects

Xin Li, Yan Ren, Yueguang Xue, Yiming Zhang and Ying Liu*



MINIREVIEWS

1333

MXene-based nanomaterials with enzyme-like properties for biomedical applications

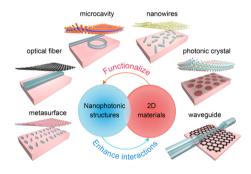
Rong Yang,* Shiqi Wen, Shuangfei Cai,* Wei Zhang,* Ting Wu and Youlin Xiong



1345

Functionalizing nanophotonic structures with 2D van der Waals materials

Yuan Meng, Hongkun Zhong, Zhihao Xu, Tiantian He, Justin S. Kim, Sangmoon Han, Sunok Kim, Seoungwoong Park, Yijie Shen, Mali Gong, Qirong Xiao* and Sang-Hoon Bae*

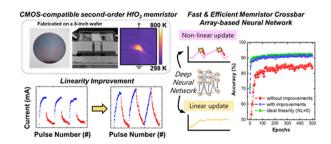


COMMUNICATIONS

1366

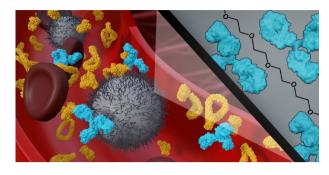
Linear conductance update improvement of CMOScompatible second-order memristors for fast and energy-efficient training of a neural network using a memristor crossbar array

See-On Park, Taehoon Park, Hakcheon Jeong, Seokman Hong, Seokho Seo, Yunah Kwon, Jongwon Lee* and Shinhyun Choi*



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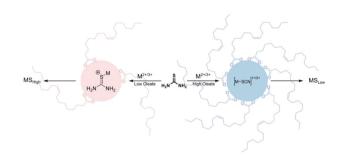
1377



Anti-PEG antibodies enriched in the protein corona of PEGylated nanocarriers impact the cell uptake

Mareike F. S. Deuker, Volker Mailänder, Svenja Morsbach* and Katharina Landfester

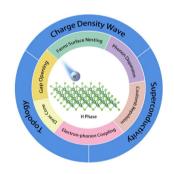
1386



Role of carboxylates in the phase determination of metal sulfide nanoparticles

Andrey A. Shults, Guanyu Lu, Joshua D. Caldwell and Janet E. Macdonald*

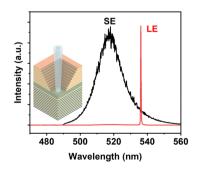
1395



Interplay of the charge density wave transition with topological and superconducting properties

Zishen Wang, Jing-Yang You, Chuan Chen, Jinchao Mo, Jingyu He, Lishu Zhang, Jun Zhou,* Kian Ping Loh* and Yuan Ping Feng*

1403



Stable continuous-wave lasing from discrete cesium lead bromide quantum dots embedded in a microcavity

Hongbo Zhang, Wen Wen, Bowen Du, Lei Zhou, Yu Chen, Shun Feng, Chenji Zou, Lishu Wu, Hong Jin Fan, Weibo Gao, Handong Sun,* Jingzhi Shang* and Ting Yu*

COMMUNICATIONS

1411

Phosphinecarboxamide based InZnP QDs - an air tolerant route to luminescent III-V semiconductors

Yi Wang, Jack Howley, Erica N. Faria, Chen Huang, Sadie Carter-Searjeant, Simon Fairclough, Angus Kirkland, Jason J. Davis, Falak Naz, Muhammad Tariq Sajjad, Jose M. Goicoechea* and Mark Green*



1417

Solvent-assisted sulfur vacancy engineering method in MoS₂ for a neuromorphic synaptic memristor

Jiyeon Kim, Changik Im, Chan Lee, Jinwoo Hwang, Hyoik Jang, Jae Hak Lee, Minho Jin, Haeyeon Lee, Junyoung Kim, Junho Sung, Youn Sang Kim* and Eunho Lee*

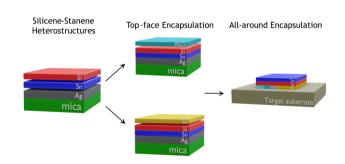
Bipolar solvent (tetrahydrofuran) Polar sulfur ion Mo

Solvent-Assisted Vacancy Engineering (SAVE)

1428

All-around encapsulation of silicene

Daya S. Dhungana, Chiara Massetti, Christian Martella,* Carlo Grazianetti* and Alessandro Molle*



1435

Atomically precise Au_xAg_{25-x} nanoclusters with a modulated interstitial Au-Ag microenvironment for enhanced visible-light-driven photocatalytic hydrogen evolution

Ye Liu, Zhi Li, Xiao-He Liu, Nicola Pinna* and Yu Wang*

